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Enhanced degradation of gaseous benzene by a Fenton reaction†

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A wet scrubbing process coupled with advanced oxidation processes (AOP) has raised great interest for the abatement of volatile organic compounds (VOCs) owing to its strong oxidation capacity and few byproducts. Fenton as an AOP has been widely used in wastewater treatment. However, the dosing method of Fenton reagents is not suitable for the treatment of continuous-flow VOCs waste-gas since H_2O_2 , a major reagent in the Fenton reaction, will be rapidly eliminated. In this study, the Fenton process was used to enhance benzene degradation in an aeration container with intermittent dosing of H_2O_2 . With the same total dosage of H_2O_2 , the benzene removal efficiency reached 85% by intermittent dosing while it was quickly decreased to 0% by dosing in a lump. The generated CO_2 by intermittent dosing of H_2O_2 is nearly 3 times that in the latter. In addition, no byproduct was generated in the gas phase. The possible pathways and mechanism of benzene degradation by the Fenton process were proposed according to the detected intermediates in the solution. This study provides a simple and efficient way to significantly enhance VOCs degradation by a Fenton reaction.

Introduction

Many volatile organic compounds (VOCs) are harmful to human health and detrimental to the atmospheric environment. Some of them have potential toxicity and carcinogenicity. They are key precursors for the formation of atmospheric secondary organic aerosols (SOA) and O3. Many attempts have been made to remove VOCs pollution using physical, chemical and biological methods,2 including absorption,3 catalytic combustion,4 photocatalytic oxidation5 and biofilters.6 However, these methods still cannot meet with the increasingly stringent discharge standards. For example, the process of adsorption just transfers VOCs from waste gas to the adsorbent but does not destroy them. Catalytic combustion needs expensive catalysts and excessive energy consumption for low-concentration VOCs. Photocatalytic oxidation has some disadvantages such as catalytic deactivation and low efficiency.7 Worst of all, these removal methods may produce intermediates, resulting in secondary gaseous pollution.8

As an alternative technology, wet scrubbing process coupled with advanced oxidation processes (AOP) has raised great interest in VOCs degradation owing to its merits such as simplicity, strong oxidation capacity and mild reaction

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conditions.^{9,10} Fenton reagent, consisting of both H_2O_2 and ferrous sulfate, as an AOP has been widely used for wastewater treatment since it can generate highly active, non-specifically but short-lived ·OH.^{11–14} The overall mechanism of the Fenton reaction is generally known by reaction (1).^{15,16}

$$Fe^{2+} + H_2O_2 \rightarrow Fe^{3+} + \cdot OH + OH^-$$
 (1)

As for wastewater treatment, the pollutants are generally well mixed with Fenton reagent. Fenton reagents, including H_2O_2 , could be dosed in a lump, generating ·OH to rapidly degrade contaminants in short time. However, such way of dosing H_2O_2 is not suitable for the treatment of waste-gas in continuous-flow since the oxidizing capacity was quickly decreased with the consumption of H_2O_2 . Recently, photo-Fenton has been used to enhance VOCs degradation^{2,17} while it requires additional UV energy and still become inefficient with the consumption of H_2O_2 . Therefore, it is of great interest to take simple and efficient steps to enhance oxidation capacity of Fenton reaction for VOCs degradation. In addition, as an emerging method for VOCs degradation, the mechanism of Fenton reaction is still not clear.

In this study, we firstly report the enhanced degradation of VOCs via the Fenton process by intermittent dosing of H_2O_2 . Toxic and refractory benzene was chosen as a representative VOC. The intermediates from benzene degradation were detected and the possible pathways and mechanism of Fenton process were proposed.

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Experimental methods

Chemicals and reagents

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In the present study the H₂O₂ (30% solution, reagent grade) was obtained from Yong Da Chemical Reagents (Tianjin) while ferrous sulfate was provided from Sinopharm Chemical Reagent. Benzene vapor, generated from passing an air stream into a benzene solution, was used as an indicative VOC. The benzene solution was saved in the refrigerator for a stable supply of VOC. The intermediates, generated from the benzene degradation, were extracted by dichloromethane. Both the liquid benzene (analytical grade) and dichloromethane (chromatographic grade) were obtained from Tianjin Fuyu Fine Chemical. Sulfuric acid, which was used to adjust the pH value of Fenton reagent, was acquired from Guangzhou Chemical Reagent Factory. All the reagents were used without any further purification.

Experimental setup

Schematic of the experimental setup is shown in Fig. 1. A continuous-flow aeration container, made of Pyrex glass with a diameter of 65 mm, height of 290 mm and effective volume of 0.5 L, was adopted for generating a stream of air containing the target pollutant. The temperature of the solution in the aeration container was kept at 25 °C by heat collection-constant temperature type magnetic stirrer (DF-101S, Gongyi Yu Hua Instrument). Air, free of CO₂, was generated from a zero air generator (HGA-5L, Beijing Huilong). The air was used to bubble through a benzene solution to generate an air stream containing high concentration of benzene vapor. The benzene vapor was diluted in the buffer and then fed to the bottom of the reactor through an aerator. Flow rate of the simulated gas was set at 1 L min⁻¹ and the initial concentration (C_0) of benzene was fixed at 25 ppm. Fenton reagents, with 4 mmol of H₂O₂ and 1 mmol of ferrous ion, were added into the aeration container. The initial pH value of the solution was adjusted to 3.0 which is the optimal value for Fenton reactions.18 The concentrations of benzene (C_t) , and CO_2 (generated from benzene oxidation) in gas phase were measured by a gas chromatograph (GC) (9790II, Fuli) equipped with two flame-ionization detectors (FID). One FID was connected with a Rt-Q-BOND PLOT column (30 m \times 0.25 mm id, film thickness 10 µm) and used for benzene analysis. The other FID equipped with a packed column (TDX-01, 3 m \times 3 mm) followed by a methanizer which was used to determine the concentrations of CO₂. Gas samples from the reaction system were dried and fed to the GC on-line by an

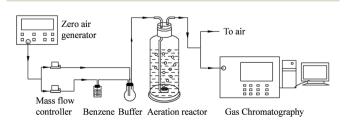


Fig. 1 Schematic of experimental setup.

automatic gas sampling valve. The intermediates from benzene degradation in the liquid and gas phase were extracted with dichloromethane and then analyzed by GC-MS (DSQII, Thermo Fisher). The acid substances, which cannot be extracted with dichloromethane from the liquid phase, were detected by the ion chromatography (DX-600, Dionex). The concentrations of H₂O₂,¹⁹ ferrous ion and total Fe ion in the solution were detected by a spectrophotometer (UV2550, Shimadzu). The concentrations of total carbon (TC), total organic carbon (TOC) and inorganic carbon (IC) were analyzed by a TOC meter (TOC-V CSH, Shimadzu).

Results and discussion

Benzene degradation by Fenton

The performance of Fenton reaction for benzene degradation was compared with that of a reference solution made up with pure water. As shown in Fig. 2, without Fenton reagent, benzene removal in the initial stage is mainly ascribed to physical absorption by the water and no CO₂ product was observed. In case of pure water, H₂O₂ and Fe²⁺ alone, benzene concentration at the outlet was quickly increased to about 22 ppm in 30 min due to the saturation of benzene absorption in the aqueous solution. As for Fenton reagent, benzene concentration sharply dropped to below 2.3 ppm and remained at about 5 ppm for 60 min, indicating that benzene was removed continuously by the Fenton reaction. The optimum $[H_2O_2]/[Fe^{2+}]$ ratio for Fenton reaction is approximately 4:1 (shown in Fig. S1†). ·OH generated by the Fenton reagents rapidly attacked the organic molecules. However, with the consumption of the Fenton reagents and the amount of ·OH reduced, leading to a decrease in benzene removal efficiency after 90 min's reaction (shown in Fig. 3). Therefore, it is highly necessary to enhance the oxidizing capacity of the Fenton reaction.

Effect of intermittent dosing of H₂O₂

In the test of intermittent dosing, 4 mmol H₂O₂ was dosed into the 0.5 L aeration container every 2 h for 4 rounds while 16 mmol H₂O₂ was dosed once at a time as for the test of H₂O₂

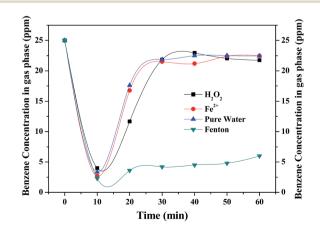


Fig. 2 Comparison of Fenton reaction and reference solution for benzene degradation.

dosing in a lump. Their performance for benzene degradation is shown in Fig. 3. Benzene removal efficiency $[=(C_0 - C_t)/C_0 \times$ 100%] in gas phase was gradually declined with the consumption of H₂O₂ in both cases. Benzene removal efficiency was kept at about 80% for nearly 90 min in the test of H₂O₂ dosing in a lump. Then, it dropped to near 0% after 150 min's reaction owing to the depletion of H₂O₂ as shown in Fig. 4. In the test of intermittent dosing of H₂O₂, the oxidizing capacity was kept for much longer time. The profiles of benzene degradation are similar in the 4 rounds of H2O2 dosing with benzene removal efficiency reached 85% in each run. After the benzene removal efficiency dropped to near 0%, the oxidizing capacity of Fenton was quickly recovered with the addition of H₂O₂. It is clear that benzene degradation via Fenton was greatly enhanced by intermittent dosing of H₂O₂. As for H₂O₂ dosing in a lump, H₂O₂ was soon consumed and abundant ·OH were generated while only part of the ·OH was used for benzene degradation due to its short-lived life. However, ·OH can be continuously generated and used for the degradation of continuous-flow benzene waste gas in the case of intermittent dosing of H₂O₂. It is expected that continuous supply of H₂O₂ or shorter interval

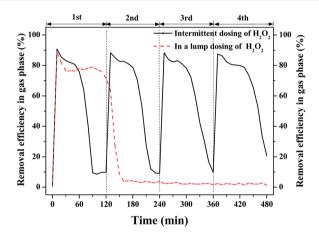


Fig. 3 Profiles of intermittent and lump dosing of H₂O₂ for benzene

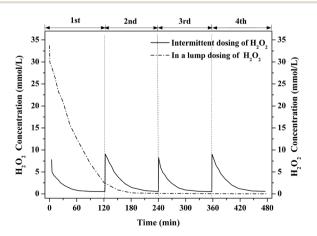


Fig. 4 The concentration change of H₂O₂ with intermittent and lump dosina

time of H₂O₂ dosing would further improve the oxidizing ability.

Fig. 5 shows the concentration of CO2 generated from benzene degradation by Fenton with the intermittent and the lump dosing cases. CO₂ was quickly generated due to the generation of ·OH through the addition of H2O2 but its concentration dropped as the H₂O₂ was gradually consumed. The CO₂ concentration reached 45 ppm after 30 min's reaction in the case of H2O2 dosing in a lump and dropped to nearly 0 ppm after 150 min's reaction. This is not completely consistent with the result of benzene removal efficiency probably due to the absorption of benzene and CO2 in the solution. As for intermittent dosing of H₂O₂, the CO₂ concentration also reached about 45 ppm for the first round while it gradually increased to about 70 ppm in the fourth round. OH can be continuously generated in the case of intermittent dosing of H₂O₂. CO₂ was formed not only from benzene degradation but also from the degradation of the intermediates in the solution. For the whole process, the CO₂ yield with intermittent dosing of H₂O₂ is nearly 3 times of that of H₂O₂ dosing in a lump. It confirms that intermittent dosing of H₂O₂ can greatly enhance VOCs and its intermediates.

Theoretically, nearly 150 ppm of CO₂ can be produced if all the removed benzene was completely oxidized into CO2. However, the measured concentration of CO₂ at outlet is much lower than the theoretical value. ~25% of CO₂ (shown in Fig. S2†) was dissolved in solution, which was confirmed by IC. The residual removal benzene was oxidized into intermediates in gas-phase or liquid phase. However, no gaseous intermediates were detected by the GC-MS, showing that no by-product was discharged in the effluent during benzene degradation by Fenton reaction. The aqueous products of benzene degradation by intermittent dosing of H_2O_2 were analyzed by a TOC analyzer. The concentrations of TC, TOC and IC in the solution are shown in Fig. 6. Both TOC and IC were detected, and the TOC concentration was much larger than the IC concentration. IC mainly comes from mineralized products from benzene degradation and TOC mainly comes from intermediates or benzene dissolved in the solution. Both the IC and TOC concentration

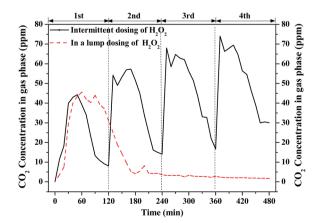


Fig. 5 Profiles of CO₂ concentration with intermittent and lump dosing of H₂O₂

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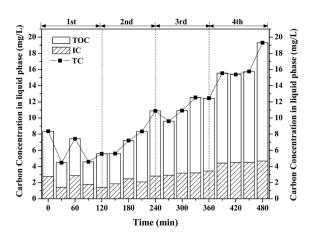


Fig. 6 Profiles of carbon in liquid with intermittent dosing of H₂O₂.

increased, from 1.5 mg L^{-1} to 4.6 mg L^{-1} and from 2.6 mg L^{-1} to 14.8 mg L⁻¹, respectively. This indicated that the intermediates formed are soluble and could be easily trapped in the solution. The TOC concentration decreased after each dosing of H₂O₂, indicating that part of the intermediates were further oxidized by the Fenton reaction. This agrees well with the observed results of CO₂ concentration variation profile shown in Fig. 5.

Mechanism of benzene degradation

Benzene degradation by Fenton reaction in an aeration container involves gas-liquid mass transfer of gaseous benzene and the following oxidation of dissolved benzene in the liquid, as shown in Fig. 7. Gaseous benzene was transferred into the liquid phase through the bubbling and the transfer rate of absorption is proportional to the driving force. 16 As shown in Fig. 2, water has poor capacity for benzene absorption. However, the quick degradation of dissolved benzene in the solution can promote continuous benzene absorption.

Fenton reaction involves electron transfer, leading to the generation of ·OH with strong oxidation capacity. The generation of \cdot OH is characterized by the reaction (1).

 Fe^{2+} initiates the decomposition of H_2O_2 to generate ·OH. Fig. 8 shows the profiles of the concentration of Fe ions in the solution with intermittent dosing of H₂O₂. In the first round, the concentration of Fe^{2+} rapidly dropped from 101.0 mg L^{-1} to 2.1 mg L⁻¹ as H₂O₂ was added into the solution and slightly increased to 7 mg L⁻¹, indicating that partial Fe³⁺ can also be recovered to Fe²⁺, according to Fenton-like reactions (2) and (3).20,21

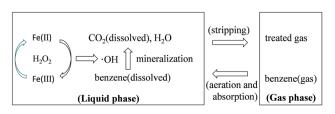


Fig. 7 Schematic of benzene degradation by Fenton reaction in an aeration container.

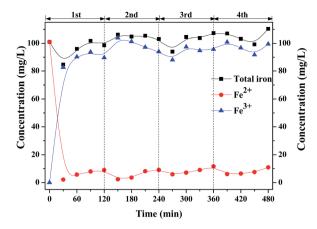


Fig. 8 Profiles of the concentration of Fe ions in liquid with intermittent dosing of H₂O₂.

$$Fe^{3+} + H_2O_2 \rightarrow Fe^{2+} + HO_2 + H_2O$$
 (2)

$$Fe^{3+} + HO_2 \cdot \rightarrow Fe^{2+} + O_2 + H^+$$
 (3)

As shown in Fig. 8, most of them were converted into Fe³⁺ which seems difficult to be reduced back to Fe^{2+} through H_2O_2 , whose reaction rate constant is only 0.02 M⁻¹ s⁻¹.²²⁻²⁴ Future work should be focused on the efficient transfer path of Fe³⁺ back to Fe2+.

The gaseous and aqueous intermediates from benzene degradation were identified by the GC-MS and the ionchromatograph. No intermediates from benzene degradation were detected in the gas phase, which can prevent the discharge of gaseous by-products.17 As listed in Table 1, the intermediates

Table 1 Intermediates of benzene degradation by Fenton process in the liquid phase

No.	Intermediates	Structure
1	Phenol	OH
2	Pyrocatechol	ОН
3	P-Benzoquinone	0=
4	Formic acid	$HO \bigcirc O$
5	Acetic acid	ОН
6	Oxalic acid	О ОН

Paper

OH

Fig. 9 Mechanism and pathways of benzene degradation by Fenton process.

in the solution are mainly phenolic, p-benzoquinone and acid substances dissolved. Phenol, observed by the GC-MS at m/z 94, is the main by-product in liquid for the Fenton process. The intensity of phenol peaks was gradually increased with intermittent dosing of H_2O_2 (shown in Fig. S3†), which accounts for the increased TOC concentration (Fig. 6). The residual phenol in solution can be easily removed by dosing more Fenton regent^{25–27} or treated in a separate sewage treatment process. Thus, Fenton also can be used as pretreatment method for the degradation of low-concentration VOCs.

Based on the intermediates above, the possible pathways of benzene degradation were composed of benzene ring excitation and pyrolysis. ·OH is highly active and rapidly attack benzene and its degradation intermediates, generating CO₂ and H₂O.^{28–30} It was reported that benzene could be dehydrogenated and cleaved by ·OH, forming unsaturated hydrocarbon and radicals.³¹ The unsaturated hydrocarbon can react with active hydrogen and oxygen, generating aldehydes.³² The aldehydes were further oxidized into acid substances such as formic acid, acetic acid and oxalic acid.³³ The excited benzene ring is firstly oxidized by ·OH to form phenol, which is further oxidized into pyrocatechol and *p*-benzoquinone.^{34,35} According to the detected products and by-products, the probable pathways of benzene degradation by the Fenton process were proposed as shown in Fig. 9.

Conclusions

In this study Fenton reaction was used for VOCs degradation in an aeration container. Benzene degradation was greatly enhanced by intermittent dosing of H_2O_2 . With the same total dosage of H_2O_2 , benzene removal efficiency reached 85% and the oxidation capacity was kept for longer time with intermittent dosing of H_2O_2 while the removal efficiency quickly decreased to 0% for the case of H_2O_2 dosing in a lump. The generated CO_2 by intermittent dosing of H_2O_2 is nearly 3 times of that in the latter. In addition, no gaseous intermediates was generated and discharged. The intermittent dosing of H_2O_2 is demonstrated to be suitable for the degradation of continuous-flow waste-gas containing VOCs. The possible pathways and mechanism of benzene degradation by Fenton process were proposed according to the detected intermediates in the liquid phase. This study

demonstrates that Fenton reaction is a promising process for the degradation of low-concentration VOCs with few gaseous byproducts under mild reaction conditions.

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